

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

EMARK OFFICE

Applicants: Mark T. Ramsbey, Robert B. Ogle, Tommy C. Hsiao, Angela T. Hui

Tuan Duc Pham, Marina V. Plat and Lewis Shen

Assignee: Advanced Micro Devices, Inc.

Title: Polished Flash Process With Metal Gates And Improved Planarity

Serial No.: 09/430,366 Filing Date: October 28, 1999

Examiner: Chen, Jack Group Art Unit: 2813

Docket No.: M-7523 US

San Jose, California November 12, 2002

BOX RCE COMMISSIONER FOR PATENTS Washington, D. C. 20231

RESPONSE TO FINAL OFFICE ACTION

Dear Sir:

This is a response to the Final Office Action dated August 9, 2002, which has a statutorily shortened period that ends on November 12, 2002 in this case. An RCE accompanies this paper.

AMENDMENTS

Please enter the following amendments.

IN THE CLAIMS

889907 v1

By this amendment, Claims 1, 7 and 23 are amended and Claims 21 and 22 are cancelled. In accordance with 37 CFR § 1.121(c)(1)(ii), the attachment entitle "Version with markings to show changes made" provides marked up versions of the amended claims containing the newly introduced changes. The following is a clean version of the entire set of pending Claims 1, 3-7, 9-12, 14, 15 and 23.

LAW OFFICES OF SKJERVEN MORRILL LLP 25 METRO DRIVE SUITE 700 SAN JOSE, CA 95110 (408) 453-9200 FAX (408) 453-7979